

2. RECIPROCAL SPACE IN CRYSTAL-STRUCTURE DETERMINATION

resolution limit (Lynch *et al.*, 1975). The function $\rho(xy)$ includes contributions from both the positive atomic nuclei and the negative electron clouds. For underfocus (Δf negative), single atoms give dark spots in the image. The contrast reverses with defocus.

2.5.2.8. Crystal structure imaging

(a) *Introduction.* It follows from (2.5.2.43) and (2.5.2.42) that, within the severe limitations of validity of the WPOA or the PCDA, images of very thin crystals, viewed with the incident beam parallel to a principal axis, will show dark spots at the positions of rows of atoms parallel to the incident beam. Provided that the resolution limit is less than the projected distances between atom rows (1–3 Å), the projection of the crystal structure may be seen directly.

In practice, theoretical and experimental results suggest that images may give a direct, although nonlinear, representation of the projected potential or charge-density distribution for thicknesses much greater than the thicknesses for validity of these approximations, *e.g.* for thicknesses which may be 50 to 100 Å for 100 keV electrons for 3 Å resolutions and which increase for comparable resolutions at higher voltage but decrease with improved resolutions.

The use of high-resolution imaging as a means for determining the structures of crystals and for investigating the form of the defects in crystals in terms of the arrangement of the atoms has become a widely used and important branch of crystallography with applications in many areas of solid-state science. It must be emphasized, however, that image intensities are strongly dependent on the crystal thickness and orientation and also on the instrumental parameters (defocus, aberrations, alignment *etc.*). It is only when all of these parameters are correctly adjusted to lie within strictly defined limits that interpretation of images in terms of atom positions can be attempted [see *ITC* (2004, Section 4.3.8)].

Reliable interpretations of high-resolution images of crystals ('crystal structure images') may be made, under even the most favourable circumstances, only by the comparison of observed image intensities with intensities calculated by use of an adequate approximation to many-beam dynamical diffraction theory [see *ITC* (2004, Section 4.3.6)]. Most calculations for moderate or large unit cells are currently made by the multislice method based on formulation of the dynamical diffraction theory due to Cowley & Moodie (1957). For smaller unit cells, the matrix method based on the Bethe (1928) formulation is also frequently used (Hirsch *et al.*, 1965).

(b) *Fourier images.* For periodic objects in general, and crystals in particular, the amplitudes of the diffracted waves in the back focal plane are given from (2.5.2.31) by

$$\Psi_0(\mathbf{h}) \cdot T(\mathbf{h}). \quad (2.5.2.51)$$

For rectangular unit cells of the projected unit cell, the vector \mathbf{h} has components h/a and k/b . Then the set of amplitudes (2.5.2.34), and hence the image intensities, will be identical for two different sets of defocus and spherical aberration values Δf_1 , C_{s1} and Δf_2 , C_{s2} if, for an integer N ,

$$\chi_1(h) = \chi_2(h) = 2N\pi;$$

i.e.

$$\pi\lambda \left(\frac{h^2}{a^2} + \frac{k^2}{b^2} \right) (\Delta f_1 - \Delta f_2) + \frac{1}{2} \pi\lambda^3 \left(\frac{h^2}{a^2} + \frac{k^2}{b^2} \right)^2 (C_{s1} - C_{s2}) = 2\pi N.$$

This relationship is satisfied for all h, k if a^2/b^2 is an integer and

$$\Delta f_1 - \Delta f_2 = 2na^2/\lambda$$

and

$$C_{s1} - C_{s2} = 4ma^4/\lambda^3, \quad (2.5.2.52)$$

where m, n are integers (Kuwabara, 1978). The relationship for Δf is an expression of the Fourier image phenomenon, namely that for a plane-wave incidence, the intensity distribution for the image of a periodic object repeats periodically with defocus (Cowley & Moodie, 1960). Hence it is often necessary to define the defocus value by observation of a nonperiodic component of the specimen such as a crystal edge (Spence *et al.*, 1977).

For the special case $a^2 = b^2$, the image intensity is also reproduced exactly for

$$\Delta f_1 - \Delta f_2 = (2n + 1)a^2/\lambda, \quad (2.5.2.53)$$

except that in this case the image is translated by a distance $a/2$ parallel to each of the axes.

2.5.2.9. Image resolution

(1) *Definition and measurement.* The 'resolution' of an electron microscope or, more correctly, the 'least resolvable distance', is usually defined by reference to the transfer function for the coherent imaging of a weak phase object under the Scherzer optimum defocus condition (2.5.2.44). The resolution figure is taken as the inverse of the U value for which $\sin \chi(U)$ first crosses the axis and is given, as in (2.5.2.45), by

$$\Delta x = 0.66C_s^{1/4}\lambda^{3/4}. \quad (2.5.2.45)$$

It is assumed that an objective aperture is used to eliminate the contribution to the image for U values greater than the first zero crossing, since for these contributions the relative phases are distorted by the rapid oscillations of $\sin \chi(U)$ and the corresponding detail of the image is not directly interpretable in terms of the projection of the potential distribution of the object.

The resolution of the microscope in practice may be limited by the incoherent factors which have the effect of multiplying the WPOA transfer function by envelope functions as in (2.5.2.49).

The resolution, as defined above, and the effects of the envelope functions may be determined by Fourier transform of the image of a suitable thin, weakly scattering amorphous specimen. The Fourier-transform operation may be carried out by use of an optical diffractometer. A more satisfactory practice is to digitize the image directly by use of a two-dimensional detector system in the microscope or from a photographic recording, and perform the Fourier transform numerically.

For the optical diffractometer method, the intensity distribution obtained is given from (2.5.2.43) as a radially symmetric function of U ,

$$\begin{aligned} I(U) &= |\mathcal{F}I(xy)|^2 \\ &= \delta(U) + 4\sigma^2 |\Phi(u)|^2 \cdot \sin^2 \chi(U) \cdot E^2(U), \end{aligned} \quad (2.5.2.54)$$

where $E(U)$ is the product of the envelope functions.

In deriving (2.5.2.54) it has been assumed that:

(a) the WPOA applies;

(b) the optical transmission function of the photographic record is linearly related to the image intensity, $I(xy)$;